

6.730 Physics for Solid State Applications

Lecture 26: Inhomogeneous Solids

Outline

- Electrochemical Potential
- Inhomogeneous Solids in Equilibrium
- PN Junctions


April 9, 2004

Electrochemical potential

The electrochemical potential, a.k.a, the fermi level is $\mu = \left(\frac{\partial E}{\partial N}\right)_S$


The energy can be divided into two parts if the particle has charge

$$E = E_{\text{orbital, nocharge}} + E_{\text{electrostatic, withcharge}}$$


$$\mu = \left(\frac{\partial E_{\text{orbital}}}{\partial N}\right)_S + \left(\frac{\partial E_{\text{electrostatic}}}{\partial N}\right)_S$$

If the electric field is $\mathbf{E}(r) = -\nabla\phi$

then the change in electrostatic energy is $dE = -e\phi dN$

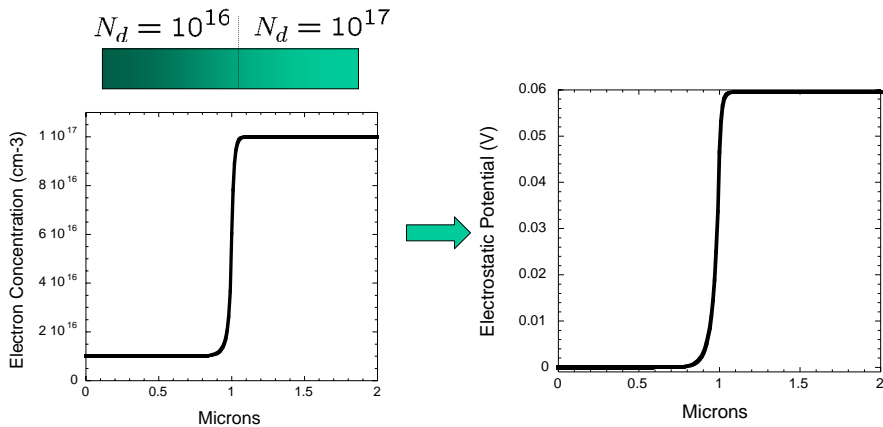

$$\mu = \mu' - e\phi(x)$$

Fermi level or the electrochemical potential the electrochemical potential for an electrically neutral particle

Inhomogeneous Semiconductors in Equilibrium

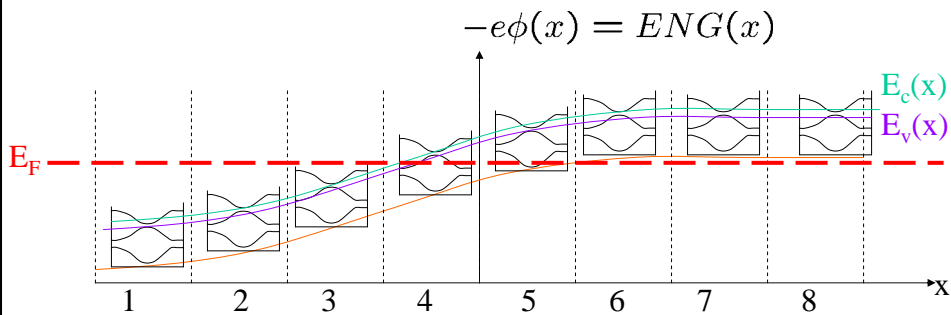
Inhomogeneous doping

Consider a solid with a spatially varying impurity concentration...



In equilibrium, the carrier concentration is balanced by an internal electrostatic potential...why?

Slowly varying potentials



1. Break up the material into regions where $\phi(x)$ is nearly constant
2. Assume Range of $\phi(x) \gg$ range of wavepacket \gg lattice constant
3. Each region has the same electrochemical potential (equilibrium) so that $\mu = \mu_i' - e \phi_i$ is the same for each region.
4. Each characteristic energy of the energy bands changes with position
5. The **electrochemical potential** $E_F = \mu$ is independent of position!

Inhomogeneous Semiconductors in Equilibrium

If electrostatic potential varies slowly compared to wavepacket...

$$\left(-\frac{\hbar^2 \nabla^2}{2m^*} + E_{co} - q\phi(r) \right) F(r) = EF(r)$$

Dividing solid into slices where ϕ_i is uniform and depends only on x...

$$-\frac{\hbar^2 \nabla^2}{2m^*} F_i(r) = (E_i - E_{co} + q\phi_i) F_i(r)$$

...the envelope function has solutions of the form...

$$F_i(r) = (A_i e^{ik_x x} + B_i e^{-ik_x x}) e^{+ik_y y} e^{+ik_z z}$$

...therefore the eigenenergies are...

$$E_i = E_{co} - q\phi_i + \frac{\hbar^2 k^2}{2m^*} \quad \longrightarrow \quad E(r) = E_{co} - q\phi(x) + \frac{\hbar^2 k^2}{2m^*}$$

Inhomogeneous Semiconductors in Equilibrium

Given the modified energy levels, the 3-D DOS becomes....

$$g(E, r) = \frac{1}{2\pi^2 \hbar^3} (2m^*)^{3/2} [E - E_{co} + q\phi(r)]^{1/2}$$

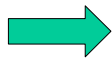
...in equilibrium the carrier concentration is with $\mu = E_F$...

$$\begin{aligned} n(r) &= \int_{E_{co}-q\phi(r)}^{\infty} g(E, r) \frac{1}{1 + e^{(E-E_F)/k_B T}} dE \\ &= \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_{co} + q\phi(r)}{k_B T} \right) \\ &\approx N_c \exp \left(\frac{-(E_{co} - q\phi(r) - E_F)}{k_B T} \right) \quad \text{Boltzmann approx.} \end{aligned}$$

Inhomogeneous Semiconductors in Equilibrium

$$n(r) = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_{co} + q\phi(r)}{k_B T} \right)$$

$$E_c(r) \equiv E_{co} - q\phi(r)$$



$$n(r) = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_c(r)}{k_B T} \right)$$

$$\approx N_c \exp \left(\frac{-(E_c(r) - E_F)}{k_B T} \right)$$

The electrostatic potential is incorporated in $E_c(r)$ or $E_v(r)$



$$p(r) = \frac{2}{\sqrt{\pi}} N_v F_{1/2} \left(\frac{E_v(r) - E_F}{k_B T} \right) \approx N_c \exp \left(\frac{-(E_F - E_v(r))}{k_B T} \right)$$

Inhomogeneous Semiconductors in Equilibrium

$$E_c(r) \equiv E_{co} - q\phi(r)$$

Density with field

$$n(r) = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_c(r)}{k_B T} \right) \approx N_c \exp \left(\frac{-(E_c(r) - E_F)}{k_B T} \right)$$

Background Density
without field

$$n_o = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_c}{k_B T} \right) \approx N_c \exp \left(\frac{-(E_c - E_F)}{k_B T} \right)$$

The potential satisfies Poisson's Equation

$$\frac{\partial^2}{\partial x^2} \phi(x) = -\frac{e}{\epsilon} [n_o(r) - n_o]$$

With boundary conditions at the interface,

$$-\epsilon_1 \frac{\partial}{\partial x} \phi_1(x) + \epsilon_2 \frac{\partial}{\partial x} \phi_2(x) = Q_{interface}$$

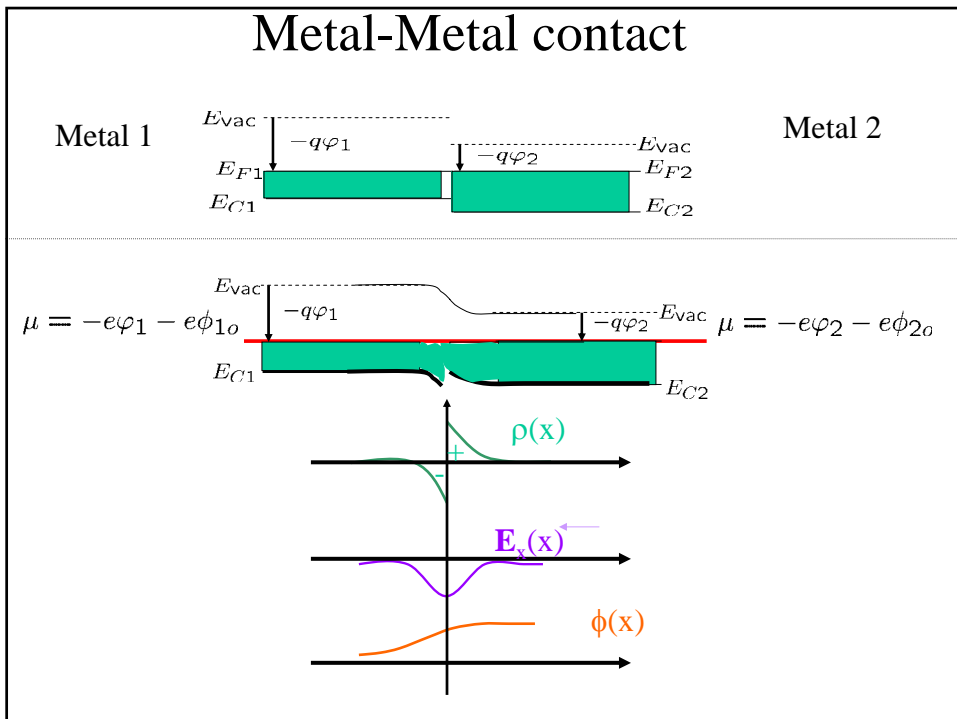
Example: Metal-Metal contact

E_{vac} is a reference level: In the absence of image forces, this is the energy needed to remove an electron from E_F so that the material no longer influences it.

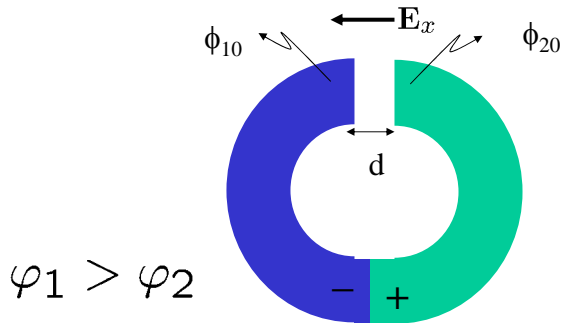


When the metals are brought together so that electrons can tunnel from one to the other, particles will be exchanged until $\bar{\mu}$ is the same.

Metal-Metal contact



electrochemical potentials and work functions



$$\varphi_1 > \varphi_2$$

The electric field in the gap $E_x = -\frac{\phi_{20} - \phi_{10}}{d}$

Recall that $\mu = -e\varphi_1 - e\phi_{10} = -e\varphi_2 - e\phi_{20}$

$$E_x = -\frac{\varphi_1 - \varphi_2}{d} \quad \text{which is the negative x direction}$$

Self-consistent potential: metals and semiconductors

$$n(r) = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_c(r)}{k_B T} \right)$$

Density with field

$$n_o = \frac{2}{\sqrt{\pi}} N_c F_{1/2} \left(\frac{E_F - E_c}{k_B T} \right)$$

Background Density without field

The potential satisfies Poisson's Equation $\frac{\partial^2}{\partial x^2} \phi(x) = -\frac{e}{\epsilon} [n(r) - n_o]$

With boundary conditions, $-\epsilon_1 \frac{\partial}{\partial x} \phi_1(x) + \epsilon_2 \frac{\partial}{\partial x} \phi_2(x) = Q_{interface}$

$$\frac{\partial^2}{\partial x^2} \phi(x) = -\frac{e}{\epsilon} [n(r) - n_o]$$

$$\approx -\frac{e}{\epsilon} \frac{\partial}{\partial E_F} n(r) |_{\phi=0} (-e\phi(x))$$

$$\approx \frac{1}{L_i^2} \phi(x) \quad \text{where the Debye length is} \quad L_i = \sqrt{\frac{\epsilon}{e^2 \frac{\partial}{\partial E_F} n}}$$

Debye Lengths

$$\frac{\partial^2}{\partial x^2} \phi(x) \approx \frac{1}{L_i^2} \phi(x)$$

where the Debye length is $L_i = \sqrt{\frac{\epsilon}{e^2 \frac{\partial}{\partial E_F} n}}$

$$\frac{\partial}{\partial E_F} n = g(E_F) \quad \text{for a metal, and } L \text{ is a fraction of an Angstrom}$$

$$\frac{\partial}{\partial E_F} n = \frac{n}{k_B T} \quad \text{for a semiconductor, and } L \text{ is a few microns}$$

Potential profile

$$\frac{\partial^2}{\partial x^2} \phi(x) \approx \frac{1}{L_i^2} \phi(x)$$

The solution for the potential is:

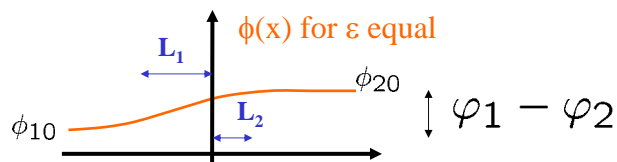
$$\phi_1(x) = \phi_{10} + A_1 e^{x/L_1} \quad \text{for } x < 0$$

$$\phi_2(x) = \phi_{20} + A_2 e^{-x/L_2} \quad \text{for } x > 0$$

with the boundary condition of no surface charge, one finds

$$\phi_1(x) = \phi_{10} + \frac{L_1/\epsilon_1}{L_1/\epsilon_1 + L_2/\epsilon_2} (\varphi_1 - \varphi_2) e^{x/L_1} \quad \text{for } x < 0$$

$$\phi_2(x) = \phi_{20} - \frac{L_2/\epsilon_2}{L_1/\epsilon_1 + L_2/\epsilon_2} (\varphi_1 - \varphi_2) e^{-x/L_2} \quad \text{for } x > 0$$



Example: PN-junction

p-doped Si

n-doped Si

